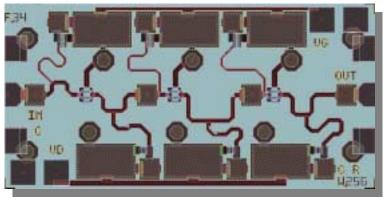


## KaLNA3S.04R\*\*\*



## **MMIC Features**

- □ Low Noise 2.5 dB N.F.
- ☐ High Gain 22 dB Gain (min)
- ☐ Frequency Range : 33-36 GHz
- $\supset$  50  $\Omega$  Zin / Zout
- >10 dB Input / Output Return Loss
- > 8 dBm Output power at 1dB gain compression
- Chip size: 1.5 mm X 0.7 mm
- Substrate Thickness: 75 μm
  - Bond Pad dimensions 100 μm x 100 μm

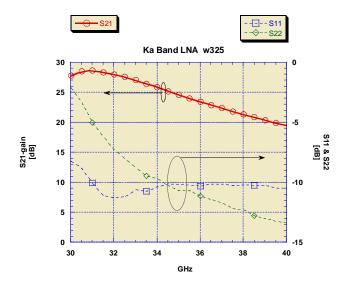
## Description

The Rockwell KaLNA3S.04R is a PHEMT low noise amplifier that operates from 33 to 36 GHz. This 3 stage amplifier has 24 dB nominal gain with 2.5 dB nominal noise figure and 1 dB gain compression of 8 dBm output power minimum. This MMIC is unconditionally stable.

**Absolute Maximum Ratings** 

Symbol	Parameters/Conditions	Min	Max	Units
V <sub>d</sub> 1 2 3	Drain Supply Voltage		5	Volts
V <sub>g</sub> 1 2 3	Gate Supply Voltage	-0.6	0.0	Volts
ld total	Total drain current		80	mA
lg total	Total gate current		0.1	mA
Pin	RF input power		30	dBm
T ch	Operating channel temperature		150	° C
T max	Max assembly temperature		300*	° C
T stg	Max storage temperature	- 65	165	° C
T base	Maximum base plate temperature		140	° C

<sup>\* 30</sup> minute maximum





## RF and Electrical Specifications Conditions T base = 25 ° C, Z source = Z load 50 +/- 5 $\Omega$

Symbol	Parameters/Conditions	Min	Тур	Max	Units
V <sub>d</sub> 1 2 3	Drain Supply Voltage	2.5	3	5	Volts
V <sub>g</sub> 1 2 3	Gate Supply Voltage	-0.6	-0.2	0.0	Volts
ID total	Total drain current (@ typ Vgs)	20	50	80	mA
Frequency	Specified Bandwidth edges	33		36	GHz
Gain**	Small signal	22	24		dB
Δ Gain	Small signal gain flatness		<1	1.2	dB/GHz
P1dB(note 1)	Power output at 1dB gain compression	8	10		dBm
RL in	Input port return loss	8	10		dB
RL out	Output port return loss	8	10		dB
Isolation	Reverse isolation	30	40		dB
NF(note 1)	Noise figure		2.5	3.0	dB

(Note 1) These measurements will be carried out on a sampled basis. A random representative sample of dies is mounted and tested for noise figure and 1 dB gain compression.

- □ Each die is fully DC tested and RF S-parameters are measured. Full 2-port S-parameter data on individual die will be supplied.
- □ All dies will pass visual inspection as dictated by the rules contained in Section A of the General Notes on Rockwell PHEMT Products (applicable sections of MIL-I-45208)
- □ Every die has a unique identifier number on-chip for complete traceability.
- □ A conductive epoxy or a flux-less solder die attach is recommended. The die should be attached to an electrically conductive surface to complete DC and RF ground paths. The ground path inductance should be minimized (<10 pH) to assure stability.
- □ The front side metal is compatible with thermo-sonic 1 mil wire bonding. The backside metal is compatible with die attach methods not exceeding Tmax.
- □ GaAs MMICs are ESD sensitive. Proper precautions should be used when handling these devices. Front and backside metal is Gold.
- (\*\*\*) Rockwell Science Center reserves the right to make improvements in this device, including die size reduction, while maintaining all RF & DC specifications. The General Notes on Rockwell PHEMT Products will be supplied upon user's request. In addition to inspection criteria it will contain descriptions, biasing instructions, reliability data.

02/18/00